Application No. 10/811,469

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## AMENDMENTS TO THE CLAIMS

This listing of claims replaces all prior versions, and listings, of claims in the application.

- (Previously Presented) A positive working heat-sensitive lithographic printing plate precursor comprising a support having a hydrophilic surface and a coating provided on the hydrophilic surface, said coating comprising:
  - -an infrared light absorbing agent,
  - -an oleophilic resin soluble in an aqueous alkaline developer,
  - -a developer resistance means and

wherein said spacer particles comprise cross-linked polysiloxane and have an average particle size is between 1 $\mu m$  and 7  $\mu m$ .

- (Canceled). 2.
- (Original) A positive working heat-sensitive lithographic printing plate precursor according to claim 1 wherein said cross-linked polysiloxane is a cross-linked polyalkylsiloxane.
- (Original) A positive working heat-sensitive lithographic printing plate precursor according to claim 1 wherein said coating has a layer thickness comprised between  $0.6 \text{ g/m}^2$  and  $2.8 \text{ g/m}^2$ .
- (Original) A positive working heat-sensitive lithographic printing plate precursor according to claim 1 wherein said coating comprises at least two layers and 5. wherein said spacer particles are present in at least one of the layers of the coating.
- (Original) A positive working heat-sensitive lithographic printing plate precursor according to claim 1 wherein the amount of said particles in the coating is between 5 and 200 mg/m<sup>2</sup>.
- (Original) A positive working heat-sensitive lithographic printing plate precursor according to claim 1 wherein said developer resistance means is a polymer comprising siloxane or perfluoroalkyl units.

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- 8. (Original) A stack comprising a plurality of positive working heat-sensitive lithographic printing plate precursors, according to claim 1, wherein adjacent plate precursors are separated by an interleave.
  - 9. (Original) A package comprising a stack according to claim 8.
  - 10. (Canceled).
  - 11. (Previously Presented) A method for improving the scuff-mark resistance of a positive working heat-sensitive lithographic printing plate precursor, the precursor comprising a support which includes a hydrophilic surface and a coating provided on the hydrophilic surface, the method comprising providing a support and hydrophilic surface, preparing a coating comprising: an infrared light absorbing agent, an oleophilic resin soluble in an aqueous alkaline developer, a developer resistance means, and spacer particles, wherein the spacer particles comprise cross-linked polysiloxane and have an average particle size between 1μm and 7 μm, and applying the coating onto the hydrophilic surface.
    - 12. (New) A method of preparing a positive working heat-sensitive lithographic printing plate precursor comprising a support having a hydrophilic surface and a coating provided on the hydrophilic surface, the method comprising providing a coating comprising:
    - cross-linked polysiloxane spacer particles having an average particle size between 1  $\mu m$  and 7  $\mu m$ ,
      - an infrared light absorbing agent,
      - an oleophilic resin soluble in an aqueous alkaline developer, and
      - a developer resistance means.